

#16/Supp  
Response  
8/8/02  
Hayes

PATENT  
97-CT-174

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:	)	
RAFFAELE ZAMBRANO	)	Group Art Unit: 2823
Serial No.: 09/191,743	)	
Filed: November 13, 1998	)	Examiner: M. Estrada
For: IN-SITU DEPOSITION AND	)	
DOPING PROCESS FOR POLY-	)	
CRYSTALLINE SILICON LAYERS	)	
AND THE RESULTING DEVICE	)	

SUPPLEMENTAL RESPONSE

Commissioner for Patents  
Washington, D.C. 20231

Sir:

In the Office Action dated December 28, 2001, the previously-filed proposed drawing correction was approved by the Examiner. Applicant has obtained corrected formal drawings, which are enclosed. Applicant respectfully submits that all objections to the drawings should now be withdrawn.

I hereby certify that this correspondence  
is being deposited with the United States  
Postal Service with sufficient postage as  
first class mail in an envelope addressed  
to: Commissioner for Patents,

Washington, D.C. 20231, on 7/10/02  
Date of Deposit

Stephen Bongini  
Applicant, Assignee, or Representative

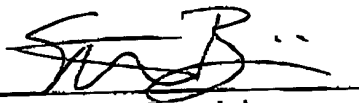
Signature

7/10/02  
Dated

-2-

Respectfully submitted,

Date: July 10, 2002

By:   
Stephen Bongini  
Registration No. 40,917  
Attorney for Applicant

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